

Heterostructure Fundamentals

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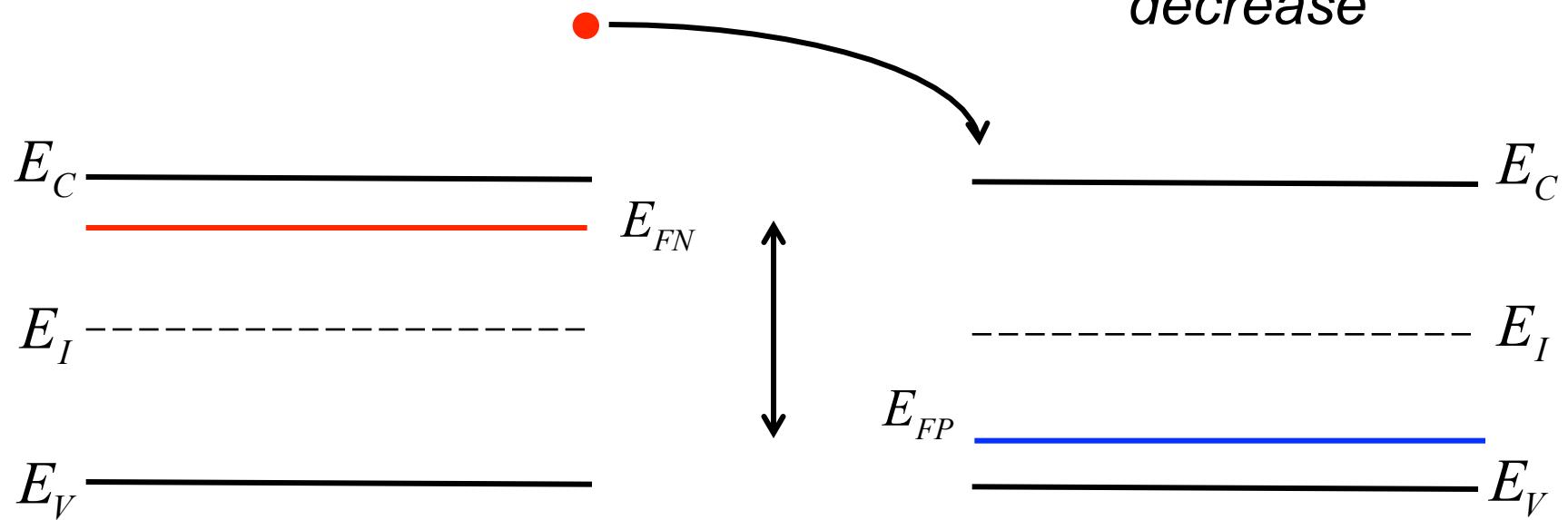
Outline

- 1) Review of energy band diagrams
- 2) Heterojunctions
- 3) General heterostructure
- 4) DD equation for heterostructures
- 5) Summary

Review: pn homojunctions

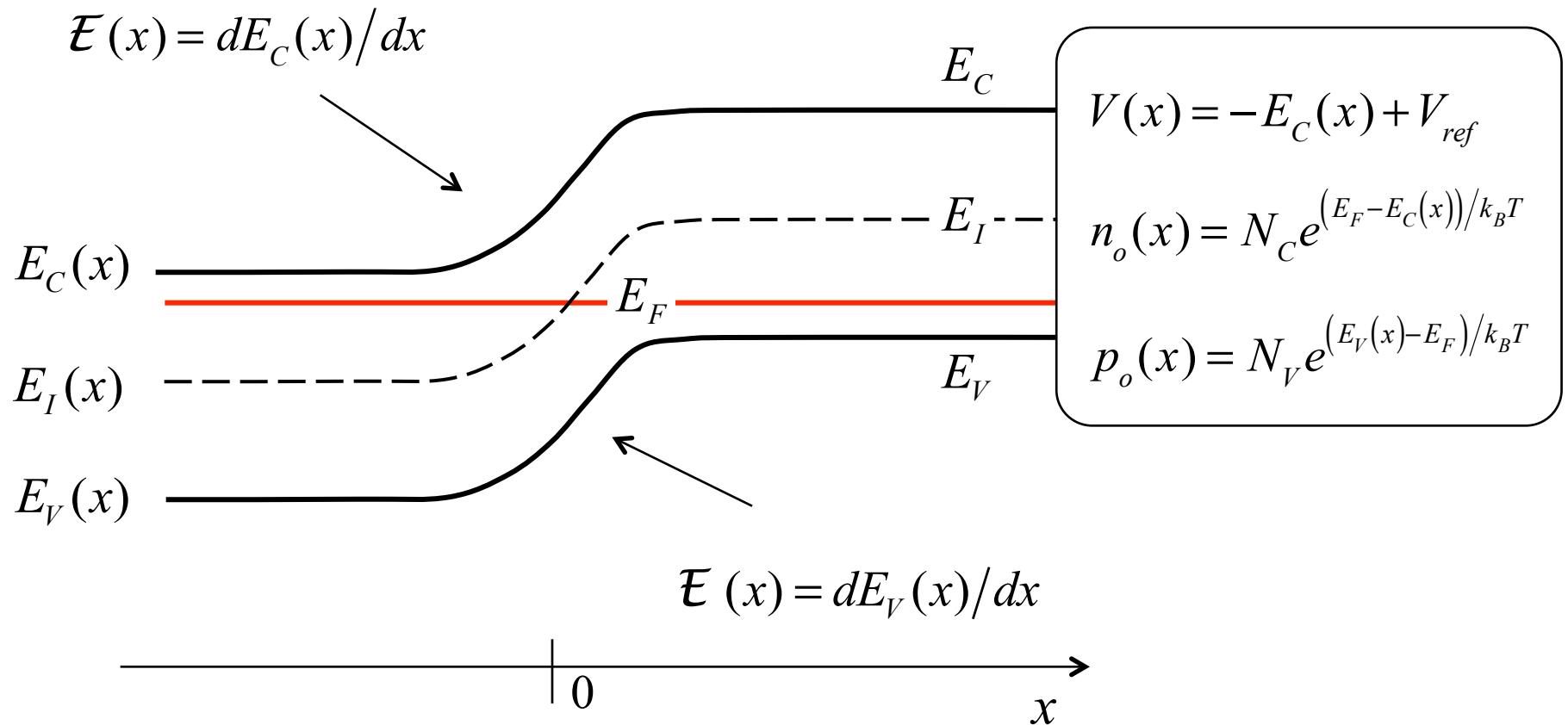
$$E = E_0 - qV$$

potential must decrease

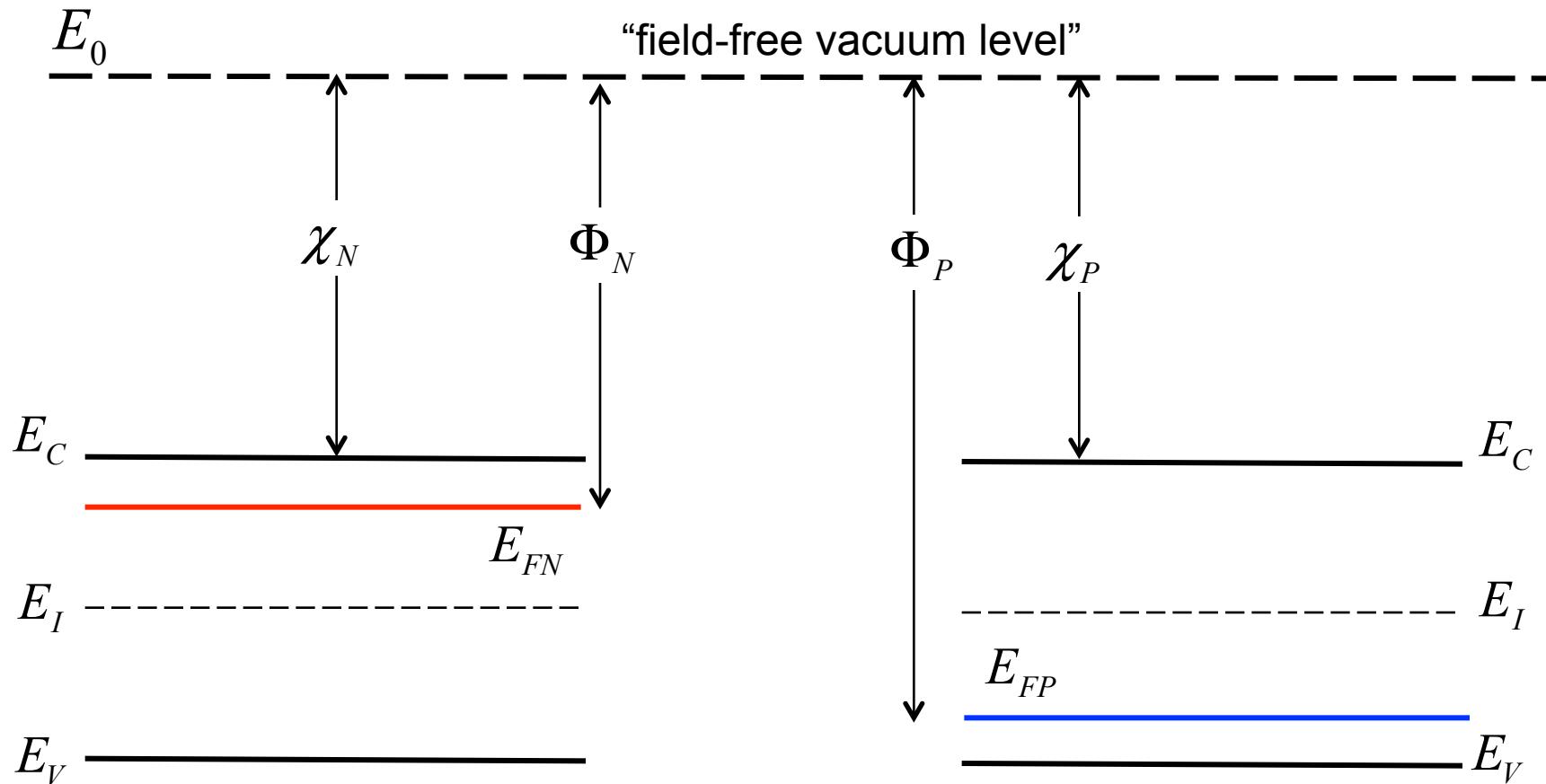


$$qV_{BI} = (E_{FN} - E_{FP})/q$$

Review: pn homojunctions



Reference for the energy bands

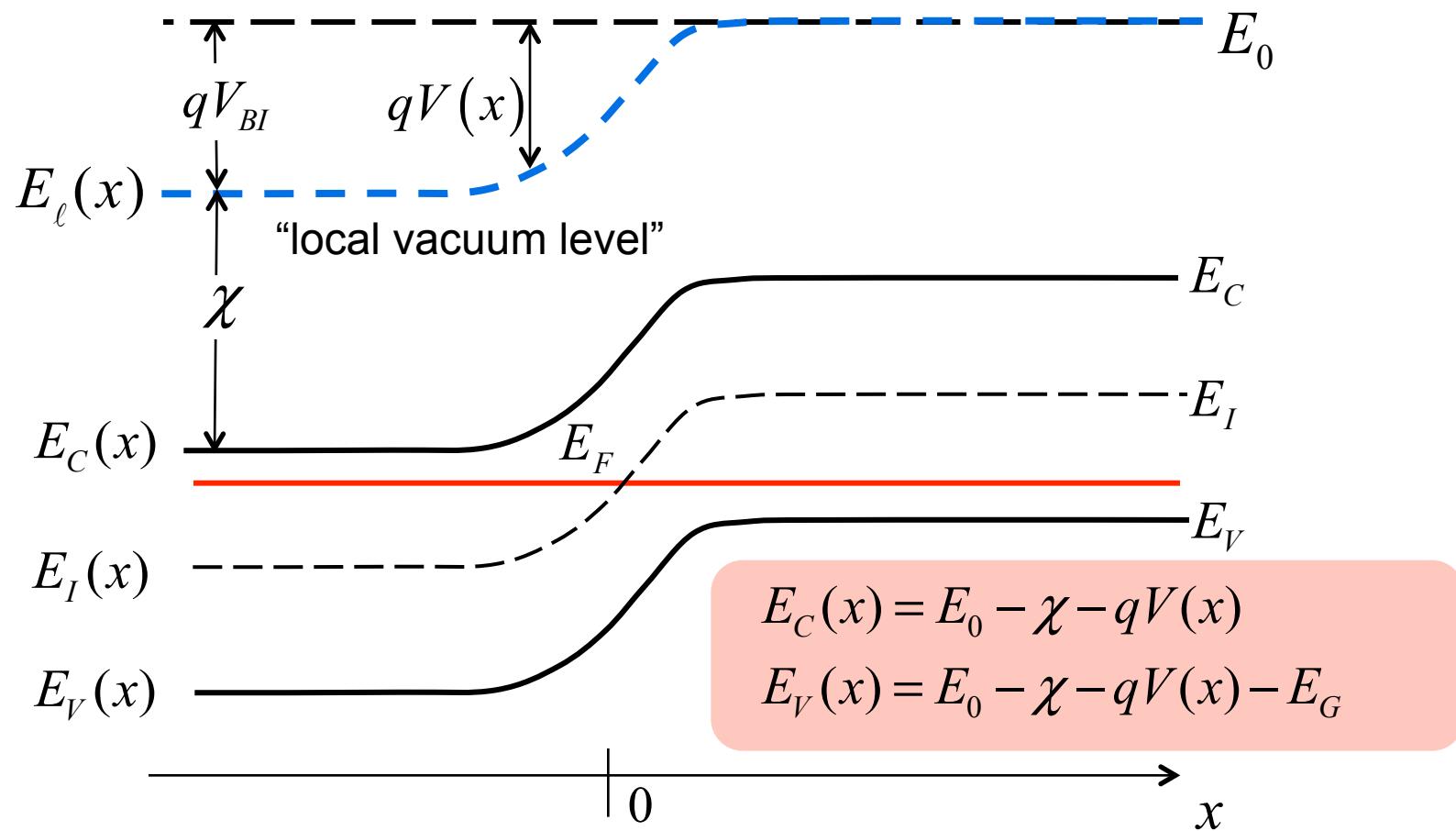


$$E_C = E_0 - \chi$$

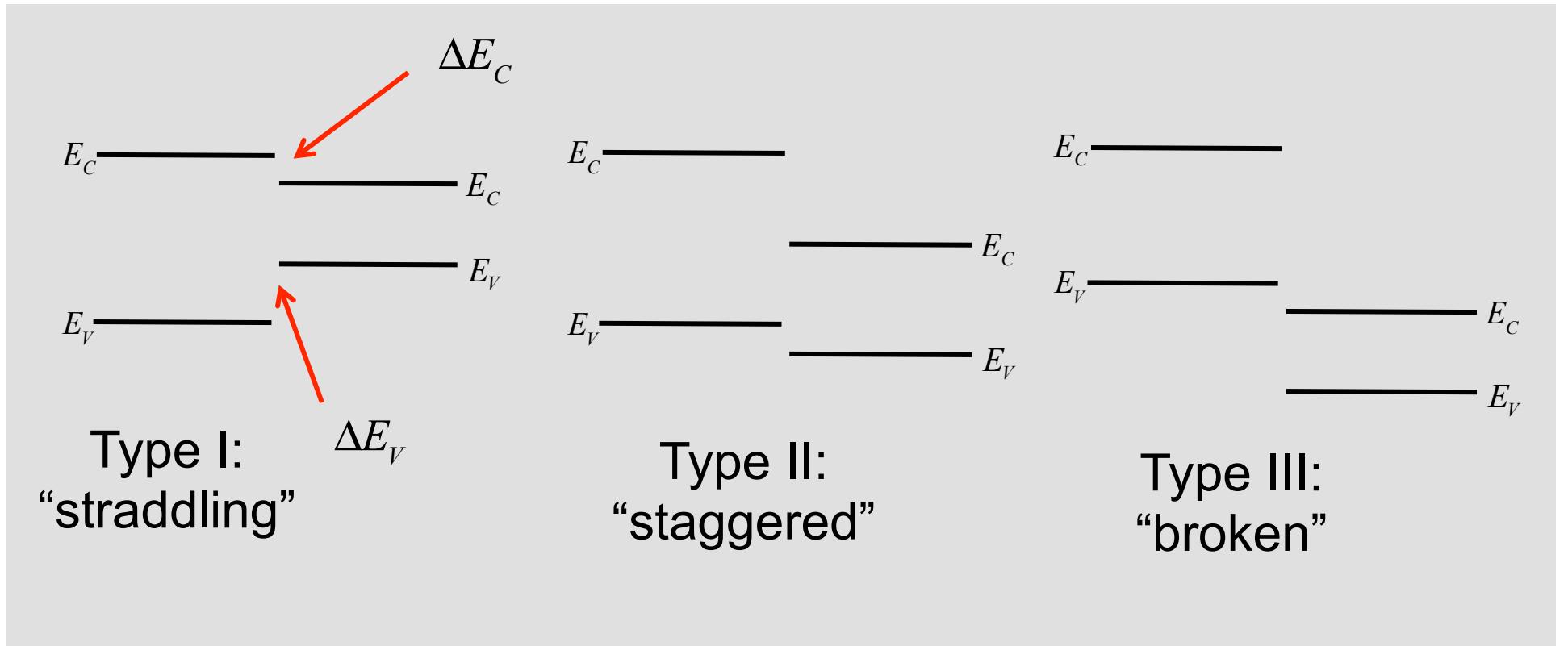
$$E_V = E_0 - \chi - E_G$$

$$qV_{BI} = (\Phi_P - \Phi_N)$$

Local vacuum level

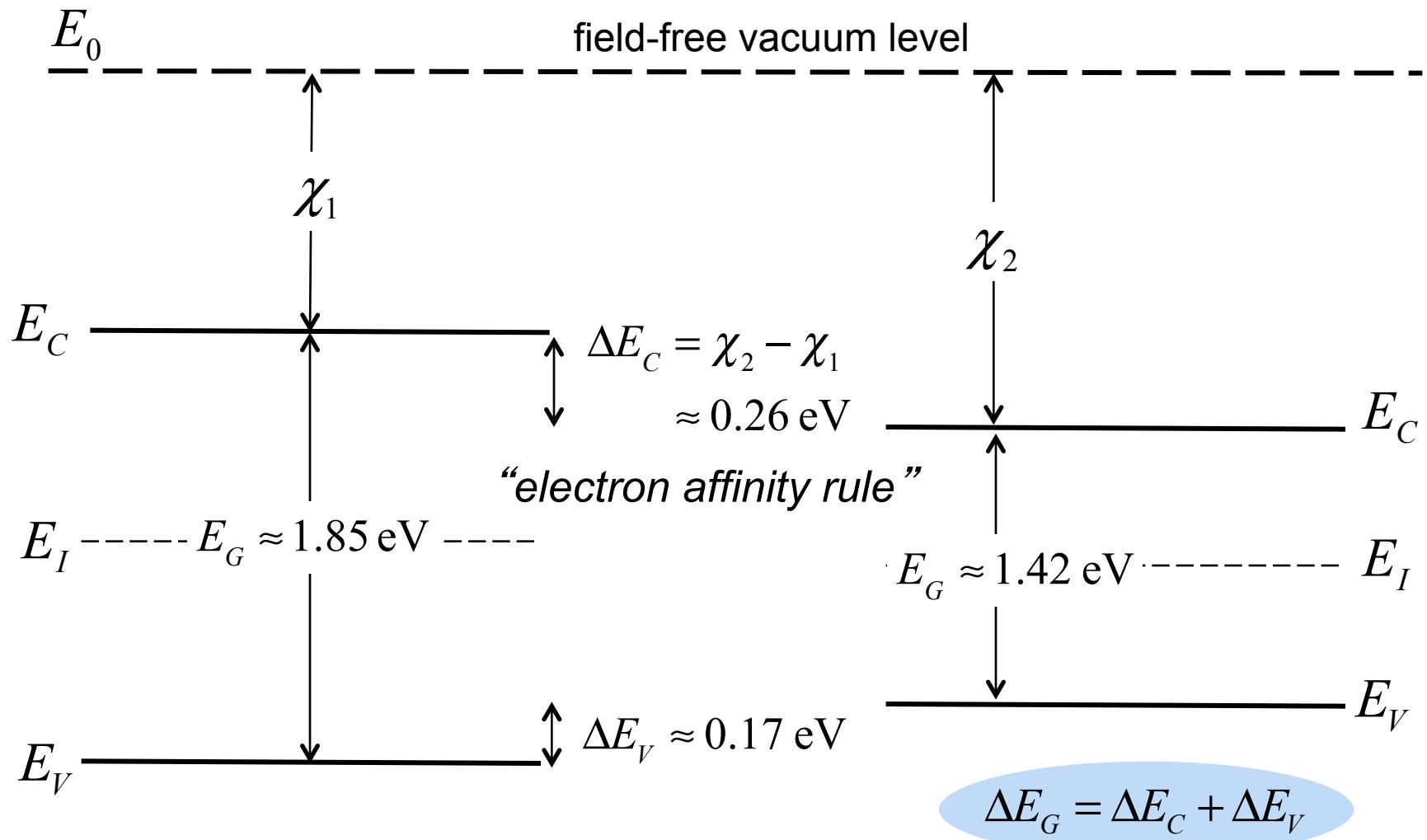


Types of heterojunctions

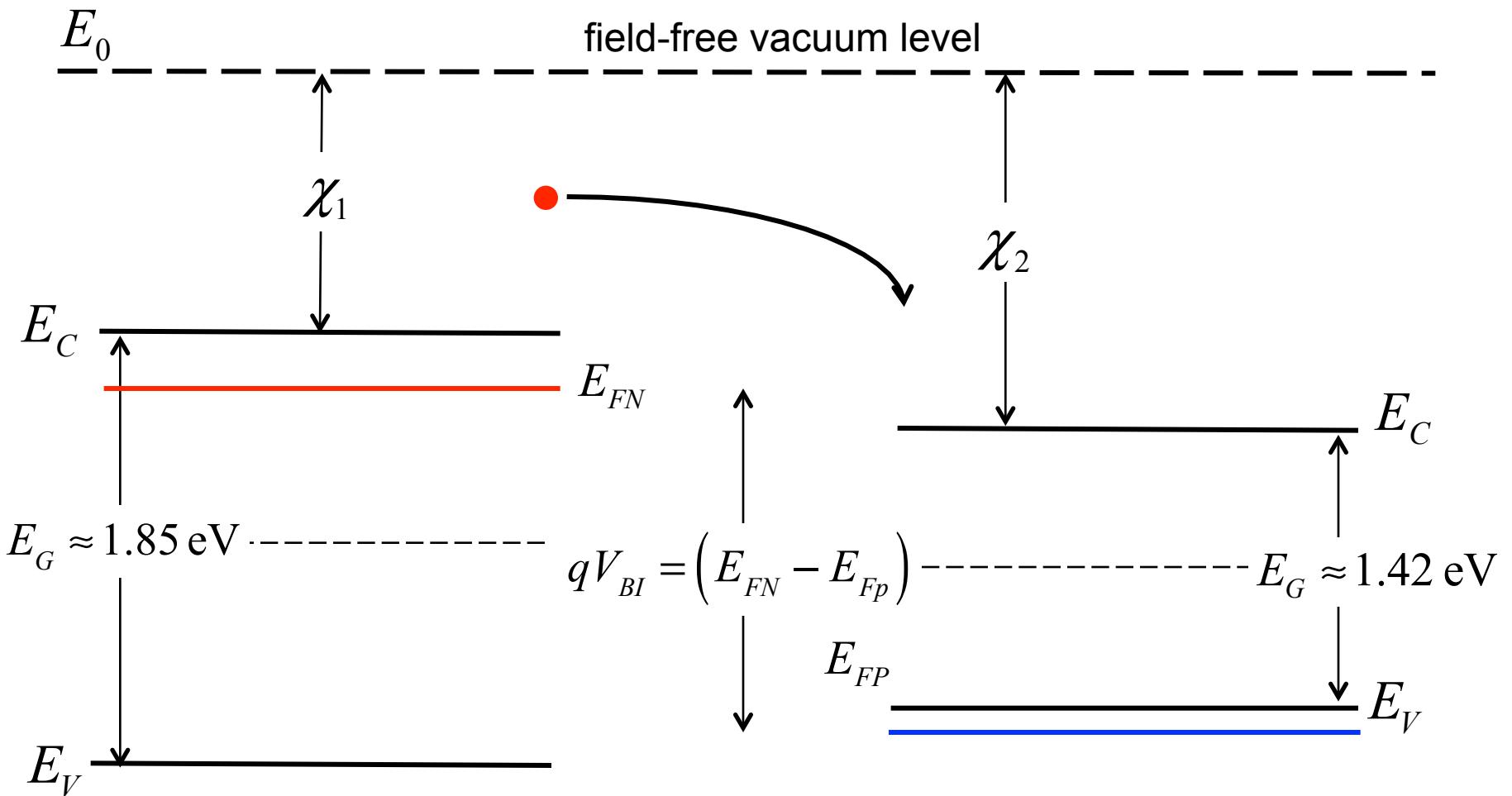


“band alignment” is a critical factor.

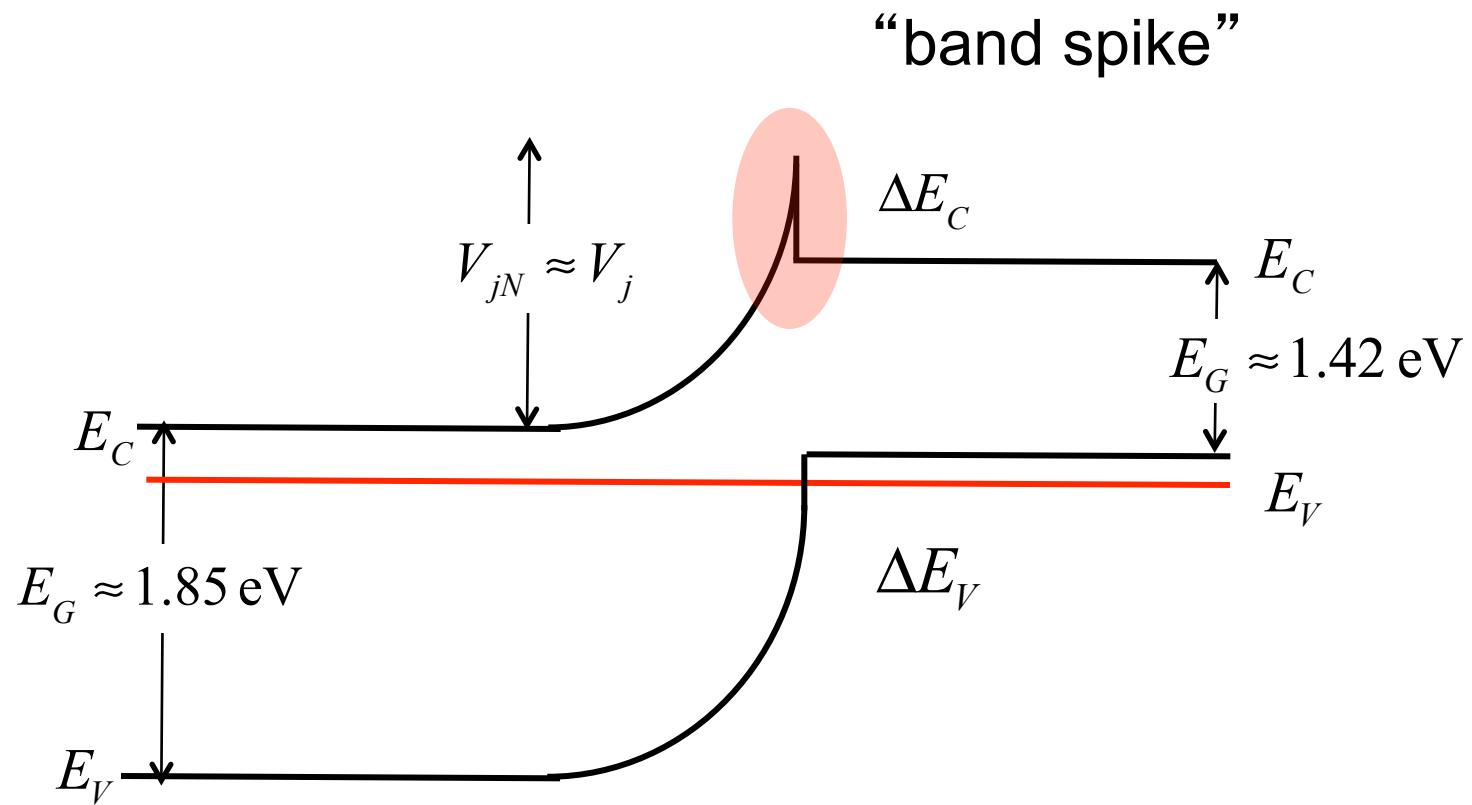
$\text{Al}_{0.3}\text{Ga}_{0.7}\text{As : GaAs}$ (Type I HJ)



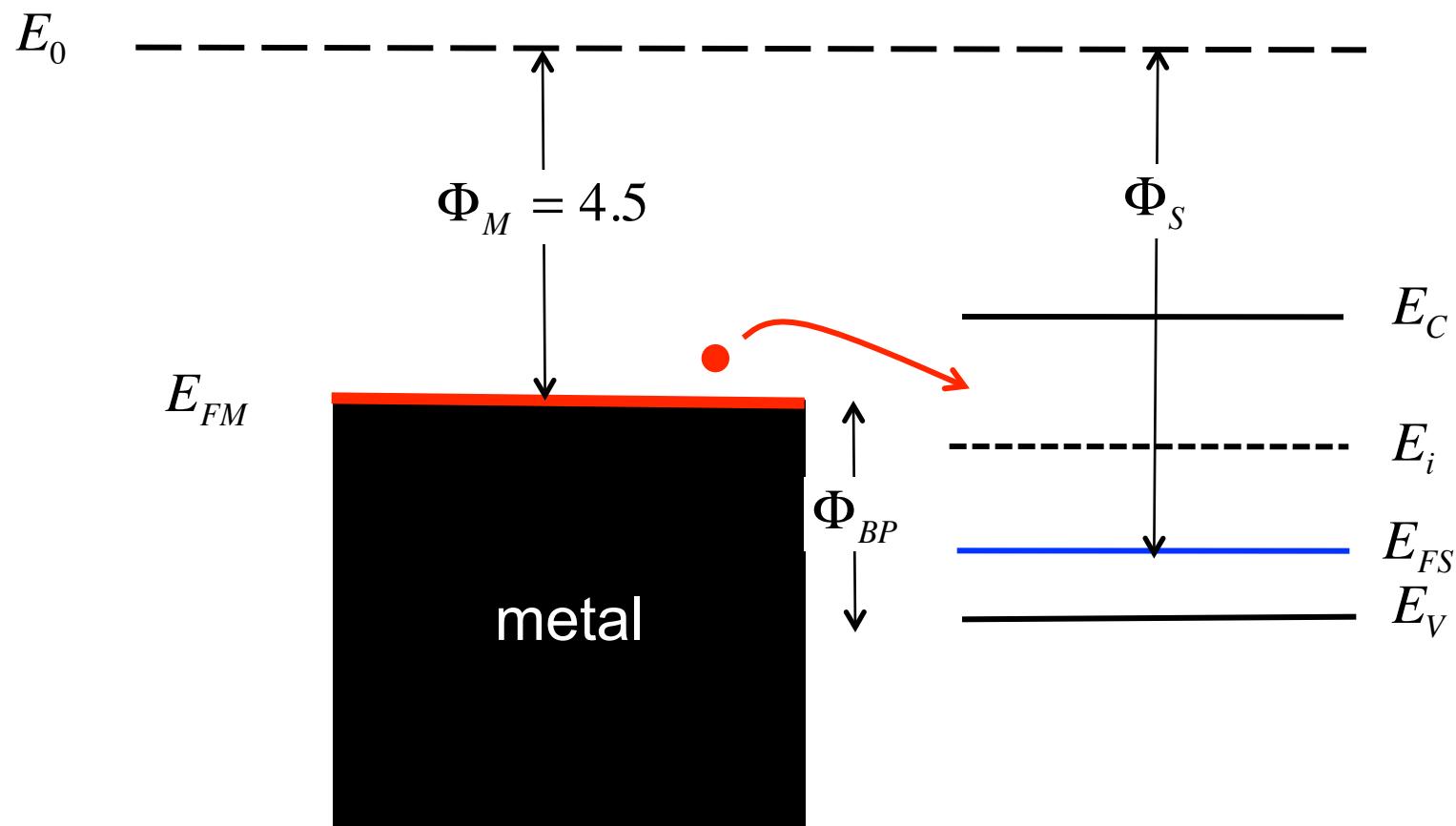
N-Al_{0.3}Ga_{0.7}As : p⁺-GaAs (Type I HJ)



N-Al_{0.3}Ga_{0.7}As : p⁺-GaAs (Type I HJ)

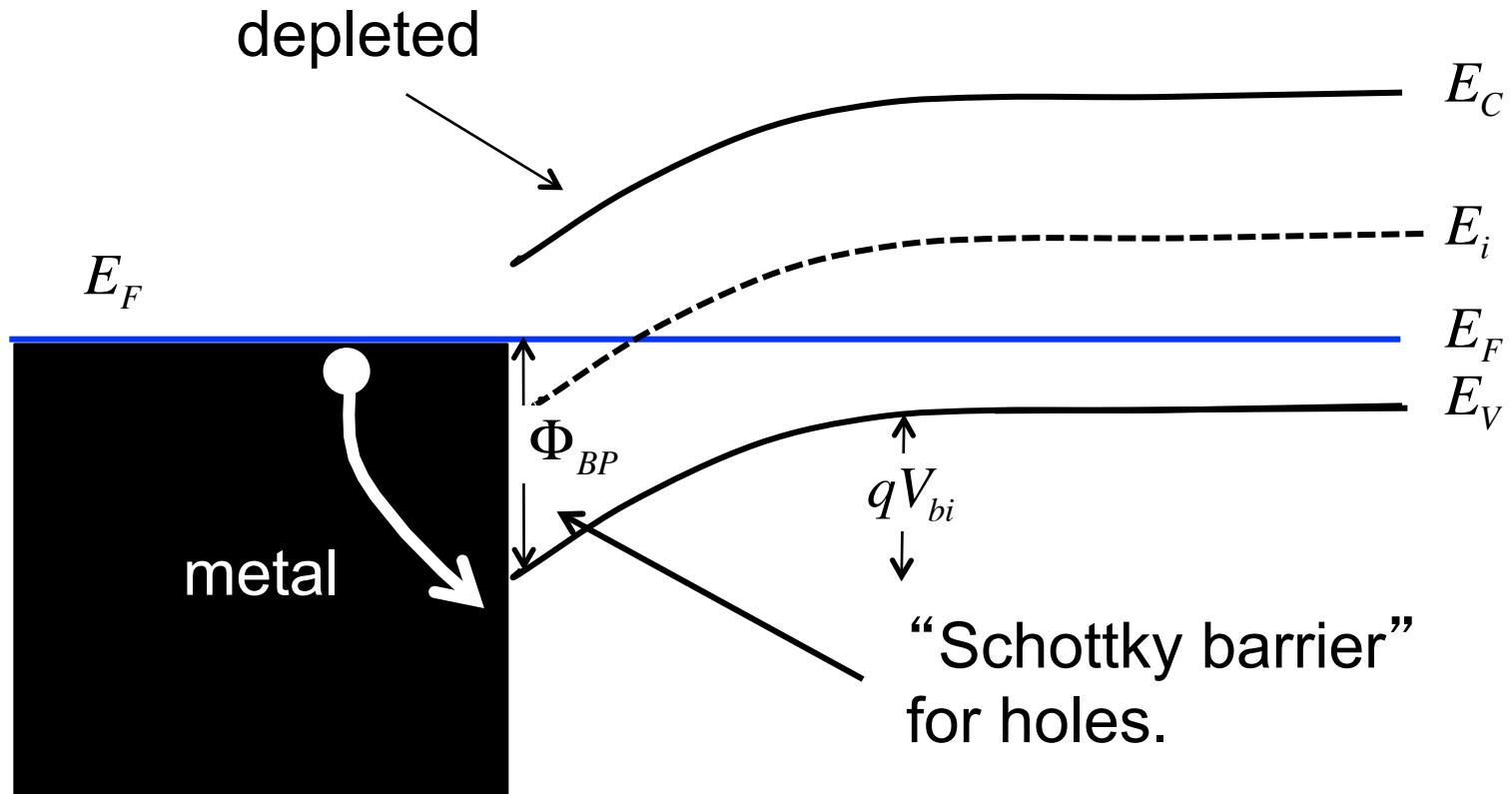


Metal-Semiconductor heterojunctions

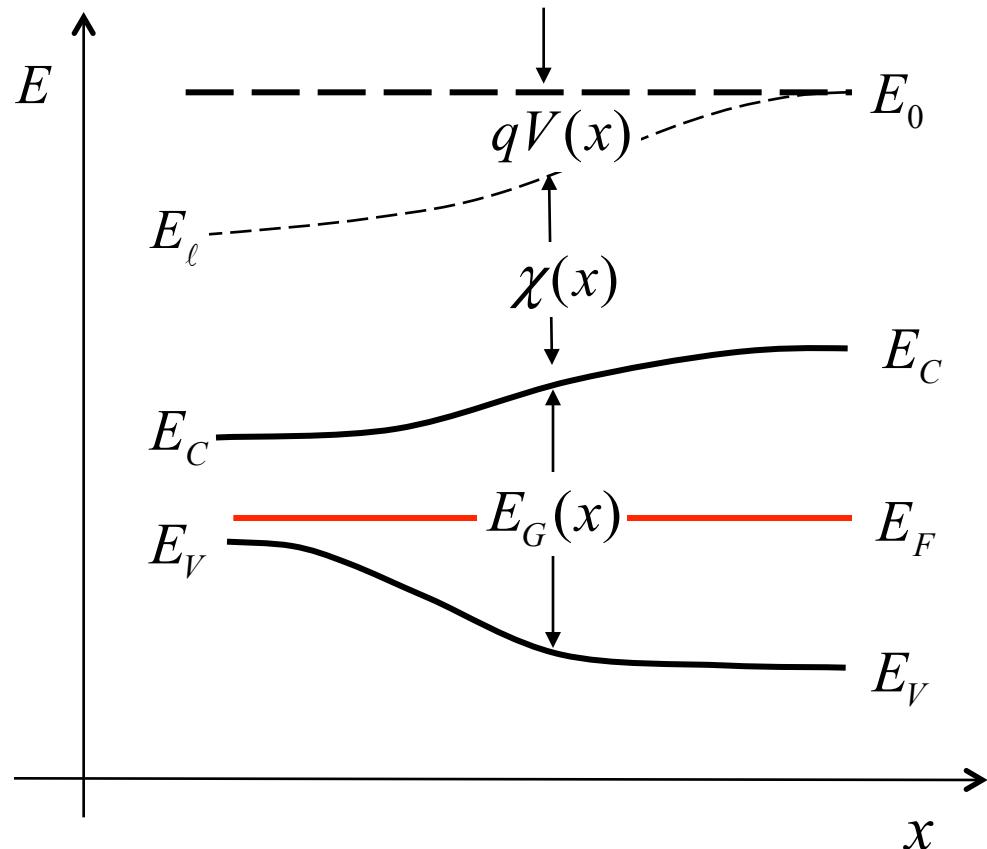


MS diode: equilibrium band diagram

from the band diagram....potential, e-field, p(x), rho(x)



General, graded heterostructure

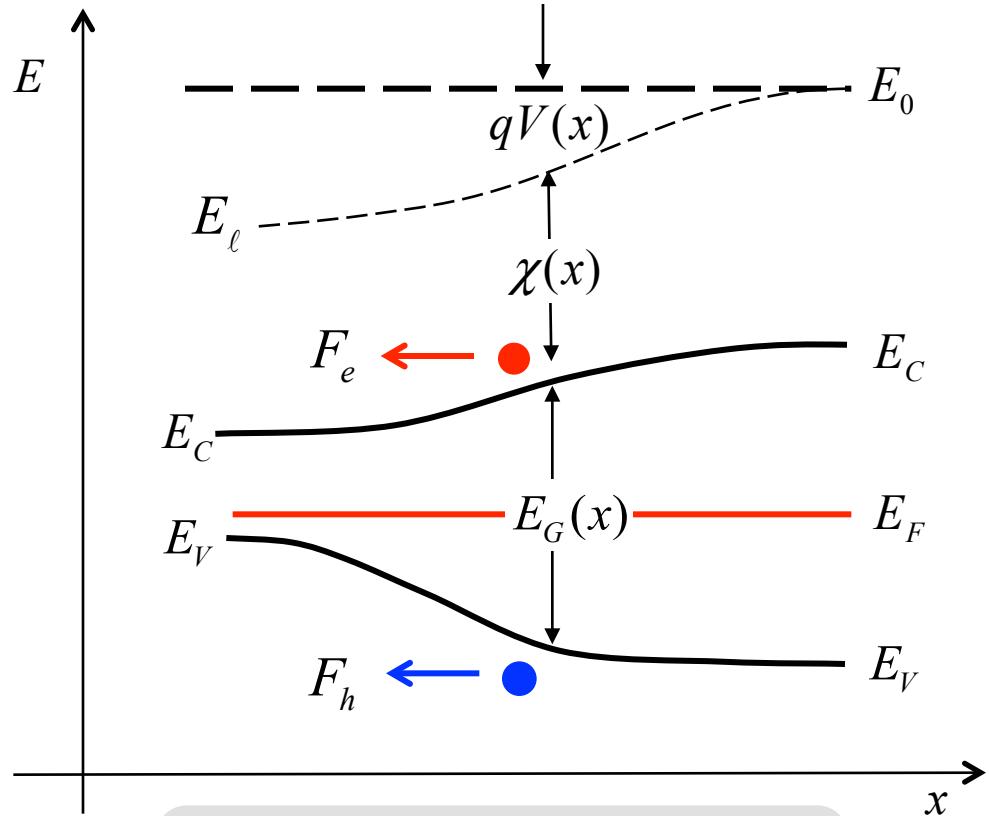


$$E_C(x) = E_0 - \chi(x) - qV(x)$$

$$E_V(x) = E_C(x) - E_G(x)$$

A smooth and slow variation of the composition is assumed.

“Quasi-electric fields”



$$E_C(x) = E_0 - \chi(x) - qV(x)$$

$$E_V(x) = E_C(x) - E_G(x)$$

$$F_e = -\frac{dE_C}{dx} = q \frac{dV}{dx} + \frac{d\chi}{dx}$$

$$F_e = -q\mathcal{E}(x) - q\mathcal{E}_{QN}(x)$$

$$\mathcal{E}_{QN} \equiv -\frac{1}{q} \frac{d\chi}{dx}$$

$$F_h = +\frac{dE_V}{dx} = -q \frac{dV}{dx} - \frac{d(\chi + E_G)}{dx}$$

$$F_h = +q\mathcal{E}(x) + q\mathcal{E}_{QP}(x)$$

$$\mathcal{E}_{QP} \equiv -\frac{1}{q} \frac{d(\chi + E_G)}{dx}$$

DD equation for heterostructures

$$J_p = p\mu_p \frac{dF_p}{dx} \quad p = N_V(x) e^{(E_V - F_p)/k_B T} \quad F_p = E_V(x) - k_B T \ln(p/N_V)$$

$$\frac{dF_p}{dx} = \frac{dE_V(x)}{dx} - k_B T \left[\frac{1}{p} \frac{dp}{dx} - \frac{1}{N_V} \frac{dN_V}{dx} \right]$$

$$J_p = p\mu_p \left[\frac{dE_V(x)}{dx} + \frac{k_B T}{N_V} \frac{dN_V}{dx} \right] - k_B T \mu_p \frac{dp}{dx}$$

$$\frac{dE_V(x)}{dx} = \frac{d}{dx} [E_0 - \chi(x) - qV(x) - E_G(x)] = q(\mathcal{E}(x) + \mathcal{E}_{QP})$$

Hole and electron currents

$$J_p = pq\mu_p \left[\mathcal{E} + \mathcal{E}_{QP} + \frac{k_B T}{q} \frac{1}{N_V} \frac{dN_V}{dx} \right] - qD_p \frac{dp}{dx}$$

“DOS effect”

$$J_n = nq\mu_n \left[\mathcal{E} + \mathcal{E}_{QN} - \frac{k_B T}{q} \frac{1}{N_C} \frac{dN_C}{dx} \right] + qD_n \frac{dn}{dx}$$

quasi-electric fields

$$\mathcal{E}_{QP} \equiv -\frac{1}{q} \frac{d(\chi + E_G)}{dx} \quad \mathcal{E}_{QN} \equiv -\frac{1}{q} \frac{d\chi}{dx}$$

Summary

- 1) Band offsets are critical parameters.
- 2) In graded heterostructures, we need to consider electric fields and quasi-electric fields.
- 3) The slope of the conduction band gives the quasi-electric field for electrons – not the electric field.
- 4) The slope of the valence band gives the quasi-electric field for holes – not the electric field.

